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piezoelectric/electrostrictive film element in  $\lambda$  manufacturing method of various film devices using the ceramics.

Considering the continuous continuous mainly used for the ceramic sol solution are dip coating, spin coating, electrochemical oxidation/reduction etc. while methods used for the ceramic oxide powder are various printing, molding, electrophoretic deposition (EPD) etc.

Among these methods, EPD is a method to mold an elaborate film, using the polarization of each component by electric polarity and the stacking property of solid particles.

In the EPD process using a ceramic oxide powder in Figure 2, ceramic particles of average diameter not less than 1 µm made by solid phase process are dispersed in dequate dispersion medium of water or organic dispersant, then they are mixed with a pH-controlling medium to make a sol solution controlled of surface electric charge, which the colloidal suspension is used for ceramic to move to cathode or anode to form a film on substrate. Which film is vapor deposited by thermal treatment vabove 1000°C, eventually to form the film.

EPD like this has  $\tilde{\Lambda}$  advantage to make a high quality film unrestricted  $\tilde{M}$  area or thickness using a simple equipment.

But there needs a separate operation to disperse powder using a dispersant, in order to secure dispersibility, because large particle diameter powder is used, and there is inevitability problem of high temperature thermal treatment to get material property peculiar of ceramic because formed film property is similar to bulk.

SUMMARY OF THE INVENTION

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The present invention to solve the problems has purpose of firstly a method to form a piezoelectric/electrostrictive film element through electrophoretic deposition and thermal treatment at low temperature using ultrafine ceramic oxide powder which is very excellent in reactivity as well as it is very fine in particle size as it has been made by single process at low temperature by combustion method using the citric acid as a combustion aid and of secondly the provision and supply of piezoelectric/electrostrictive film element formed by the method at low temperature.

The present invention to achieve the purpose, features method for forming piezoelectric/electrostrictive film element forms at low temperature using electrophoretic deposition, comprising the steps of : preparing a solution or a dispersed mixture containing constituent ceramic elements by dissolving or dispersing the raw material of constituent ceramic elements in a solvent or a dispersion medium; preparing a mixed solution by adding citric acid into the solution or the dispersed mixture in which the constituent ceramic elements are dissolved or dispersed; getting ultrafine ceramic oxide powder of particle size less than 1  $\mu \mathrm{m}$  with uniform particle diameter size distribution, by forming ceramic oxide without scattering over, by nonexplosive oxidative-reductive combustion reaction by thermally treating the mixed solution at 100-500°C; preparing a suspension by dispersing the ultrafine ceramic oxide powder in  $\checkmark$  an organic dispersant; preparing ceramic sol solution by dissolving constituent ceramic elements of same or similar constituents with the ultrafine ceramic oxide powder in water or

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with the ceramic sol solution

an organic solvent; dispersing by mixing the suspension in which the ultrafine ceramic oxide powder is dispersed with the ceramic sol solution; forming a piezoelectric/electrostrictive film element by submerging a substrate into the suspension which the ultrafine ceramic oxide powder and the ceramic sol solution are mixed and then by performing electrophoretic deposition; and thermally treating the piezoelectric/electrostrictive film element at 100-600°C, so that the solvent is removed by the thermal treatment and the bonding among the ultrafine ceramic oxide powder particles is induced, while the ceramic sol acts as a reaction medium on the surfaces of the ceramic oxide particles.

invention Also the present features piezoelectric/electrostrictive film element produced by a method comprising the steps of : preparing a solution or a dispersed mixture containing constituent ceramic elements by dissolving or dispersing the raw material of constituent ceramic elements in a solvent or dispersion medium; preparing a mixed solution by adding citric acid into the solution or the dispersed mixture in which the constituent ceramic elements are dissolved or dispersed; getting ultrafine ceramic oxide powder of particle size less than 1  $\mu\mathrm{m}$  with uniform particle diameter size distribution by forming ceramic oxide without scattering over, by nonexplosive oxidative-reductive combustion reaction by thermally treating the mixed solution at 100-500°C; preparing a suspension by dispersing the ultrafine ceramic oxide powder in an organic dispersant; .preparing ceramic sol solution by dissolving constituent ceramic elements of same or similar